



IFW

AMENDMENT TRANSMITTAL LETTER

Docket No.
27427.002.00

Application No.
10/699,654

Filing Date
November 4, 2003

Examiner
Anthony T. Perry

Art Unit
2879

Applicant(s): Sung Hun KIM

Invention: SHADOW MASK STRUCTURE FOR CATHODE RAY TUBE

TO THE COMMISSIONER FOR PATENTS

Transmitted herewith is an amendment in the above-identified application.

The fee has been calculated and is transmitted as shown below.

CLAIMS AS AMENDED					
	Claims Remaining After Amendment	Highest Number Previously Paid	Number Extra Claims Present	Rate	
Total Claims	24	- 26 =	0	x 50.00	0.00
Independent Claims	5	- 5 =	0	x 200.00	0.00
Multiple Dependent Claims (check if applicable) <input type="checkbox"/>					
Other fee (please specify):					
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT:					\$0.00

☒ Large Entity

☐ Small Entity

☐ No additional fee is required for this amendment.

☐ Please charge Deposit Account No. _____ in the amount of \$ _____.
A duplicate copy of this sheet is enclosed.

☒ A check in the amount of \$ _____ \$0.00 _____ to cover the filing fee is enclosed.

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☒ The Director is hereby authorized to charge and credit Deposit Account No. _____ 50-0911
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☒ Credit any overpayment.

☒ Charge any additional filing or application processing fees required under 37 CFR 1.16 and 1.17.

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Dated: May 31, 2005

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Docket No.: 27427.002.00
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
KIM, Sung Hun

Customer No.: 30827

Application No.: 10/699,654

Confirmation No.: 5375

Filed: November 4, 2003

Art Unit: 2879

For: SHADOW MASK STRUCTURE FOR
CATHODE RAY TUBE

Examiner: Anthony Perry

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

In response to the Office Action dated April 19, 2005, please amend the patent application identified above as follows:

INTRODUCTORY COMMENTS

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 7 of this paper.